Supporting Information

$NiCo_2O_4$ Nanostructures Materials: Morphology Control and Electrochemical Energy Storage

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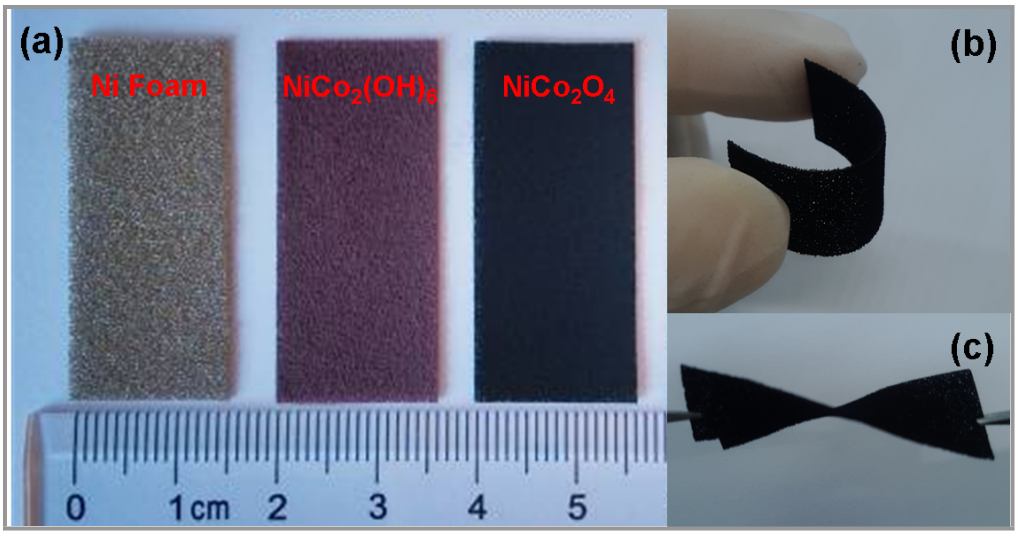

Fig. S1 Photographs of nickel foam substrate, $NiCo_2(OH)_6$ precursor on nickel foam, NCONNs on nickel foam.

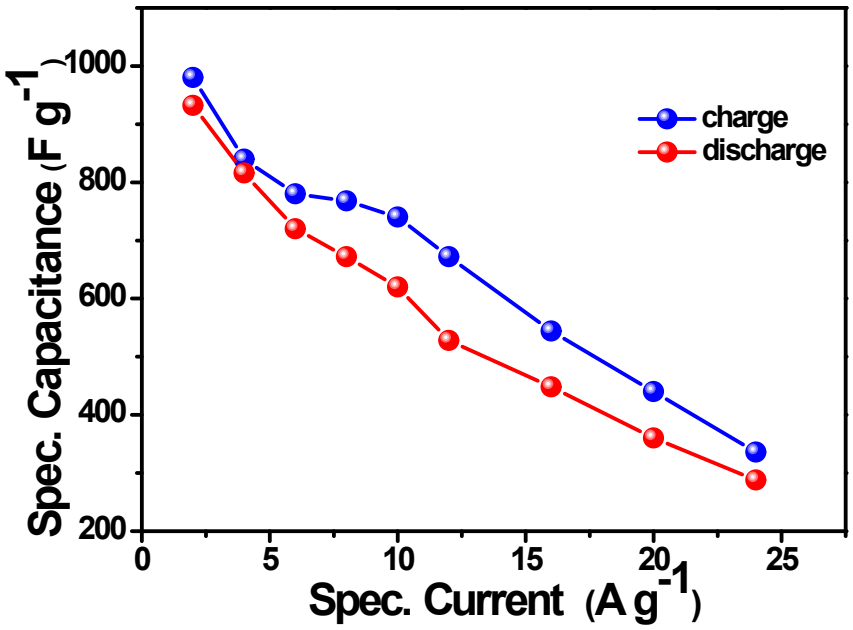

Fig. S2 Specific capacitance as a function of current density of NCONNs.

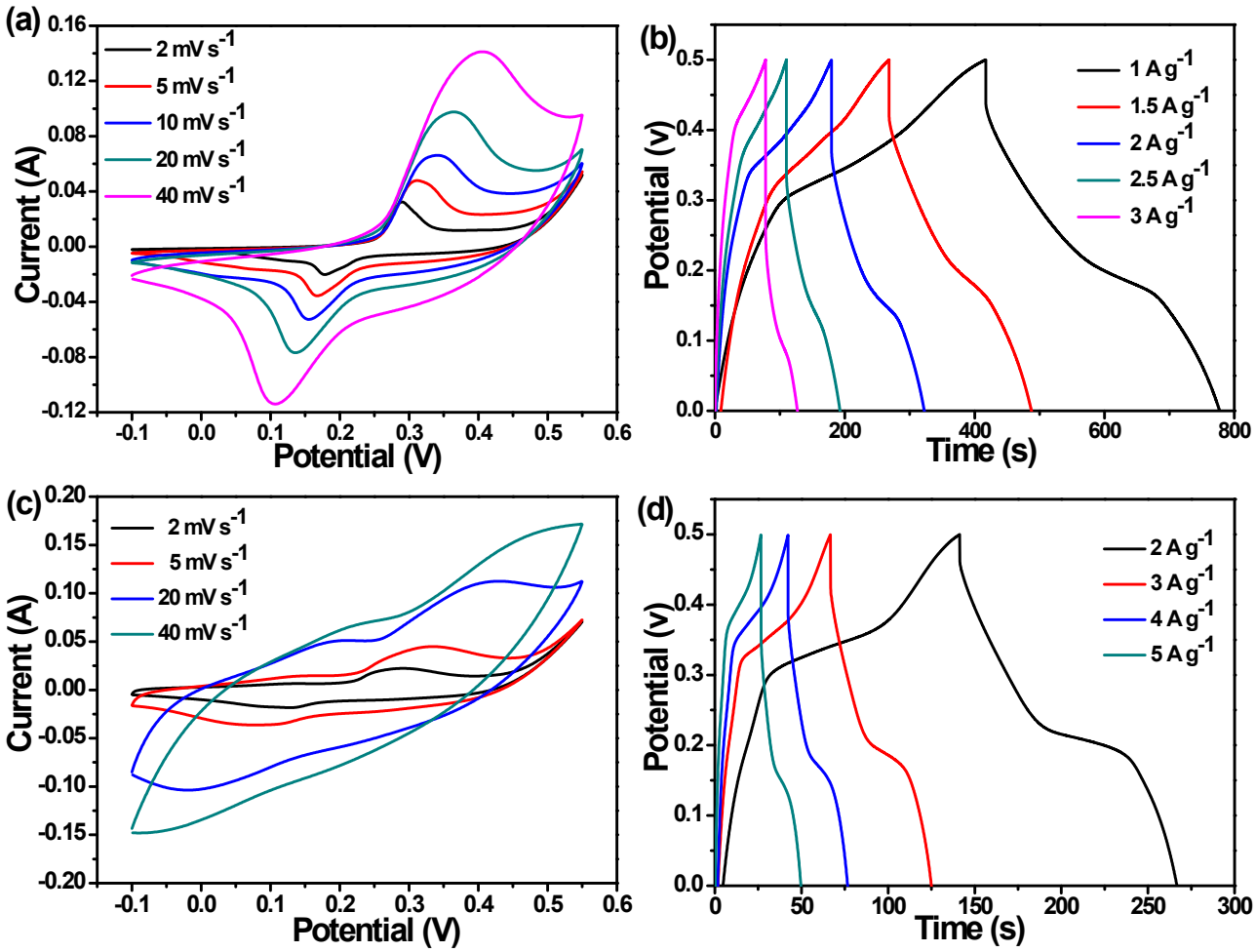

Fig. S3 (a, c) shows The CV curves and (b, d) shows the galvanostatic charge-discharge curves of the NCONSs and NCONFs, respectively.